

Patent Abstracts of Japan

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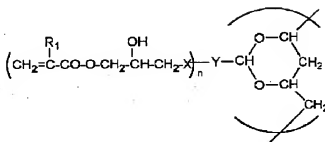
APPLICATION DATE : 21-12-98
 APPLICATION NUMBER : 10362301

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INVENTOR : TOCHISAWA TETSUAKI;

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TITLE : PHOTSENSITIVE RESIN AND
 PHOTSENSITIVE RESIN
 COMPOSITION



$R_1 = \text{Me}, \text{H}$

$n = 1, 2$



$m = 0 \sim 6$ までの整数

Y = 芳香族環または単結合

ABSTRACT : PROBLEM TO BE SOLVED: To easily obtain a photosensitive resin having wide aptitude and superior preservation stability and high sensitivity and high resolution.

SOLUTION: This photosensitive resin is a photopolymerizable type resin, having a polyvinyl acetate saponified product as a main structural chain comprising the structural units each represented by general formula I. The photosensitive resin composition is prepared by using this photosensitive resin.

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